

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention

THREE-MASK METHOD OF CONSTRUCTING THE FINAL HARD MASK USED
FOR ETCHING THE SILICON FINs FOR FINFETS

Application Number:

Confirmation Number:

First Named Applicant: Brent Anderson

Attorney Docket Number: BUR920030201US1

Search string: (6391695 or 6413802 or 6433609 or 6610576 or 6611029 or 20030102497 or 20030113970).pn.

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
<i>h</i>	1	6391695	2002-05-21	Yu	-		
<i>h</i>	2	6413802	2002-07-02	Hu et al	-		
<i>h</i>	3	6433609	2002-08-13	Voldman	-		
<i>h</i>	4	6610576	2003-08-26	Nowak	-		
<i>h</i>	5	6611029	2003-08-26	Ahmed et al	-		

US Published Applications

Note: Applicant is not required to submit a paper copy of cited US Published Applications

init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass
<i>h</i>	1	20030102497	2003-06-05	Fried, et al	-		
<i>h</i>	2	20030113970	2003-06-19	Fried, et al	-		

Signature

Examiner Name	Date
<i>Wm Hoang</i>	<i>6/5/2005</i>